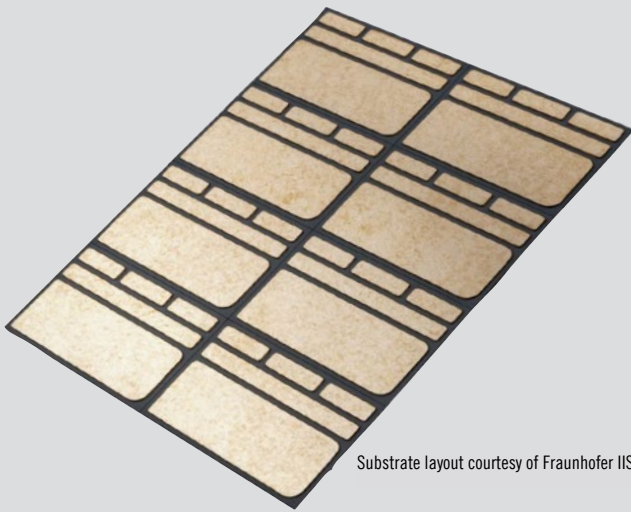


## Condura®.ultra

Condura®.ultra Si<sub>3</sub>N<sub>4</sub> Ag free substrates DPIS<sup>(1)</sup>



Substrate layout courtesy of Fraunhofer IISB

### Condura®.ultra-Si<sub>3</sub>N<sub>4</sub> Ag free AMB Substrate facts

- Silicon nitride ceramic 60 W/m·K  
Thicknesses: 0.32 mm
- Silicon nitride ceramic 90 W/m·K  
Thicknesses: 0.25mm/0.32mm
- Active Metal Brazed Cu-OFC (99.99%)  
Thicknesses<sup>(2)</sup>: 0.30 mm/0.40mm/0.50 mm/0.80mm
- Asymmetric brazing is possible up to 0.60 mm Cu thickness and a max. thickness difference of 0.10 mm
- Single unit or master card
- Surface finish: Ag optimized for silver sintering, bare Cu, Ni or NiAu selective Ag plating possible

### Key features

- Excellent reliability for automotive applications (AMB has best in class reliability)
- Thermal conductivity:
  - ≥60 W/m.K
  - ≥90 W/m.K
- Cost effective high performance substrate
- Ag free AMB technology

### Special features

- Best quality functional surfaces, e.g. Ag finish optimized for silver sintering technology
- Rimless Ag plating for more efficient and reliable surface area for bonding
- Special surface treatment to increase die shear strength
- Pre-applied sinter<sup>(3)</sup> / solder

### Main properties of Si<sub>3</sub>N<sub>4</sub> Ag free AMB

	60 W/m·K	90 W/m·K	
	Rating	Rating	Unit
Bending strength $\sigma_b$	≥650	≥650	MPa
Fracture toughness	≥6	≥6	MPa·m <sup>1/2</sup>
Thermal conductivity (@ 20 °C)	≥60	≥90	W/m·K
Coefficient of thermal expansion (20 °C - 500 °C)	2.6	2.6	10 <sup>-6</sup> /K
Young's modulus (@ 20 °C)	280	280	GPa
Dielectric strength (@ 50 Hz)	≥15	≥15	kV/mm
Volume resistivity (@ 20 °C)	>10 <sup>12</sup>	>10 <sup>12</sup>	Ω·m
Dielectric constant (@ 1 MHz)	8.1	8.1	
Dielectric loss factor (@ 1 MHz)	1.5* 10 <sup>-3</sup>	1.5* 10 <sup>-3</sup>	

(1) Development Product Information Sheet, preliminary values

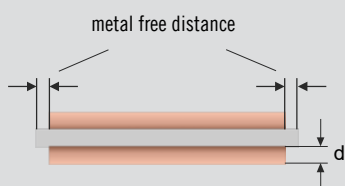
(2) Different material combinations on request

(3) Under development

# Condura®.ultra

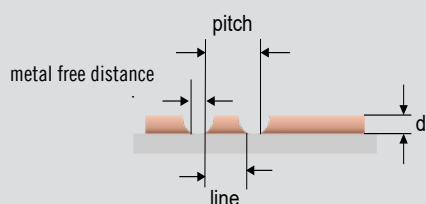
## Design Rules Condura®.ultra-Si<sub>3</sub>N<sub>4</sub> Ag free AMB DPIS<sup>(1)</sup>

### Metal free distance



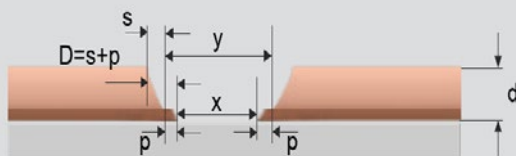
Thickness Cu d [mm]	Min. metal free distance [mm]
0.30	+/- 0.30
0.40	+/- 0.40
0.50	+/- 0.40
0.80	+/- 0.40

### Structuring



Thickness Cu d [mm]	Min. metal free distance [mm]	Min. line [mm]	Min. pitch [mm]
0.30	0.50	0.50	1.00
0.40	0.70	0.70	1.40
0.50	0.70	0.70	1.40
0.80	1.00	1.00	2.00

### Structuring tolerance



Thickness Cu d [mm]	Tolerance of structuring dimensions x, y [mm]
0.30	±0.20
0.40	±0.30
0.50	±0.30
0.80	±0.40

### Sidewall of structured pattern + protruding length

Thickness Cu d [mm]	D = sidewall of structured pattern (s) + protruding length (p*) [mm]
0.30 - 0.80	≤( 1/2 * d + 0.1mm)

(1) Development Product Information Sheet, preliminary values  
\*Typical protruding length p < 0.1mm on each flank

# Condura®.ultra

## Design Rules Condura®.ultra-Si<sub>3</sub>N<sub>4</sub> Ag free AMB DPIS<sup>(1)</sup>

### Mastercard / Single unit dimension & tolerances

Mastercard usable area	167mm · 127 mm
Single unit dimension*	≥ 15 mm · 15 mm
Tolerances	+0.2 / -0.05 mm

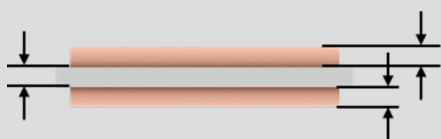
\*Smaller dimensions on request

### Thickness tolerances

	0.3 mm	0.4 mm	0.8 mm
Copper thickness (per each Cu-layer)			
Copper thickness tolerance (per each Cu-layer)	+10 / -30 µm	+10 / -30 µm	+55 / -55 µm
Ceramic thickness tolerance	± 50 µm		
Total thickness (Cu+Si <sub>3</sub> N <sub>4</sub> +Cu) tolerance	± 10 %		

Warpage behavior depends on specific layout, single unit size and material combination and can only be specified after initial sample preparation.

### Thickness combinations



Si <sub>3</sub> N <sub>4</sub> Thickness (mm)	Cu Thickness* (mm)			
	0.3	0.4	0.5	0.8
0.32	√	√	√	√
0.25	√	√	√	

\*Others on request

### Surface plating

Plating	Thickness (µm)
Ag (immersion silver)	typically 0.3
Electroless Ni	3 - 7 (9% ± 2% P)
Immersion Au (ENIG, Au Class 1)	0.01 - 0.05
Immersion Au (ENIG, Au Class 2)	0.03 - 0.13

# Condura®.ultra

## Design Rules Condura®.ultra-Si<sub>3</sub>N<sub>4</sub> Ag free AMB DPIS<sup>(1)</sup>

### Metal properties

#### Surface roughness\*

R<sub>a</sub> < 1.5 µm, R<sub>z</sub> < 16 µm

#### Copper peeling strength

> 9.8 N/mm

\*Lower roughness on request

### Customized surfaces for assembly process

Optimization of surface and assembly process parameters available or in development cooperation for:

- Silver sintering
- Solder wetting
- Heavy wire bondability

### HET Academy R&D Application Center

Besides offering Assembly Materials, Bonding Wires and Metal Ceramic Substrates, Heraeus Electronics provides matching material solutions and R&D oriented partnerships to create individual solutions.

#### Heraeus Electronics offers:

- Reliable IATF 16949 certified supply of:
  - ✓ Condura®.ultra Si<sub>3</sub>N<sub>4</sub> (Ag-free Active Metal Brazed Si<sub>3</sub>N<sub>4</sub>)
  - ✓ Condura®.prime AMB-Si<sub>3</sub>N<sub>4</sub> (Active Metal Brazed Si<sub>3</sub>N<sub>4</sub>)
  - ✓ Condura®.extra DCB-ZTA (zirconia-toughened alumina)
  - ✓ Condura®.classic DCB-Al<sub>2</sub>O<sub>3</sub> (direct copper bonded Al<sub>2</sub>O<sub>3</sub>)
- Condura®+ for example:
  - ✓ Engineering Services (Simulation, Prototype Design & Assembly, Testing and Qualification, Material Analysis)
  - ✓ Pre-applied sinter / solder
- To be your competent **one-stop materials solutions partner!**

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